**United States Design Patent**

**Hanson et al.**

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**TARGET PROFILE FOR A PHYSICAL VAPOR DEPOSITION CHAMBER TARGET**

**Applicant:** APPLIED MATERIALS, INC., Santa Clara, CA (US)

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**Term:** **15 Years**

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**LOC (10) Cl.**

**U.S. Cl.**

**Field of Classification Search**

USPC .......... D13/182; D15/144.1, 144.2, 199
CPC ........... H01L 21/67742; H01L 21/0226; H01L 21/02263; H01L 21/02266; H01L 21/02269; H01L 21/02271; H01L 2224/75186; H01L 2224/761185; H01L 2224/761386; H01L 2221/68363

See application file for complete search history.

**References Cited**

**U.S. PATENT DOCUMENTS**

D557,226 S * 12/2007 Uchio ............... D13/182
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**Other Publications**

U.S. Appl. No. 29/524,109, filed Apr. 16, 2015, Riker et al.
U.S. Appl. No. 29/524,557, filed Apr. 21, 2015, Zhang et al.

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**CLAIM**

The ornamental design for a target profile for a physical vapor deposition chamber target, as shown and described.

**DESCRIPTION**

FIG. 1 is a perspective view of a target profile for a physical vapor deposition chamber target, showing our new design;

FIG. 2 is a top plan view thereof;

FIG. 3 is a bottom plan view thereof;

FIG. 4 is a right side view thereof;

FIG. 5 is a left side view thereof;

FIG. 6 is a front view thereof;

FIG. 7 is a back view thereof; and,

FIG. 8 is a cross sectional view taken along line 8-8 in FIG. 2.

The dashed lines in FIGS. 1-8 represent disclaimed matter forming no part of the claimed design.

**1 Claim, 6 Drawing Sheets**